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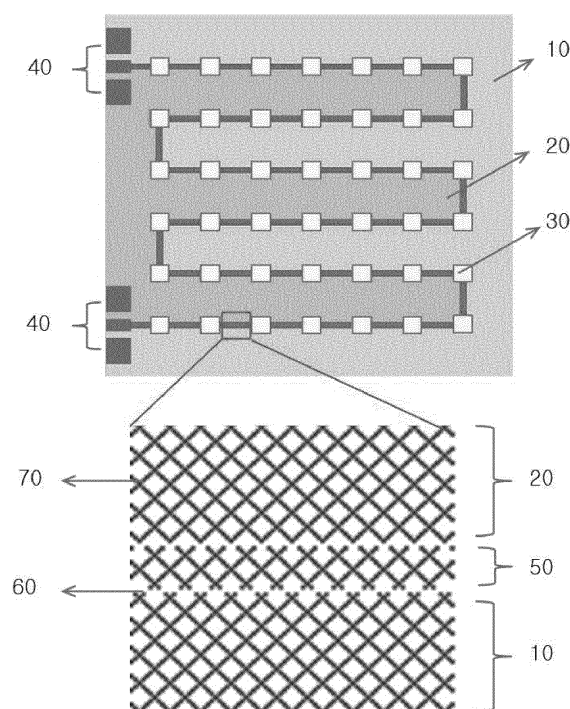
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(54) **TRANSPARENT LIGHT EMITTING ELEMENT DISPLAY**

(57) A transparent light emitting element display according to an exemplary embodiment of the present application comprises: a transparent substrate; at least one light emitting element which is provided on the transparent substrate; and a first common electrode wiring portion, a second common electrode wiring portion, and a signal electrode wiring portion which are provided on the transparent substrate, in which all of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion comprise metal mesh patterns, respectively, each of the metal mesh patterns, which constitute the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, has a standard deviation of a line width which is 20% or less, a standard deviation of a pitch which is 10% or less, and a standard deviation of a line height which is 10% or less, and the metal mesh patterns are provided in a region having an area of 80% or more of an overall area on the transparent substrate.

[Figure 1]



Description

[Technical Field]

[0001] This application claims priority to and the benefit of Korean Patent Application No. 10-2017-0096101 filed in the Korean Intellectual Property Office on July 28, 2017, the entire contents of which are incorporated herein by reference.

[0002] The present application relates to a transparent light emitting element display.

[Background Art]

[0003] Recently in Korea, various types of scenery lighting as well as gorgeous signboards are created in parks and downtowns through fusion of cutting-edge ICT technologies and cutting-edge LED technologies, thereby providing urban residents with information and spectacles. In particular, a transparent LED display made of a transparent electrode material is configured by applying the LED between glass and glass and has an advantage in that luxurious appearances may be created because no electric wire is visible. For this reason, the transparent LED display is utilized for interior decoration in hotels, department stores, and the like and increases in importance in implementing media facades of outer walls of buildings.

[0004] Demands for transparent electrodes, which are transparent, allow electricity to flow therethrough, and thus are used for touch screens or the like, are exponentially increased as smart devices come into wide use, and the most widely used transparent electrode, among the transparent electrodes, is indium tin oxide (ITO) which is oxide of indium and tin. However, the indium, which is a main ingredient of the ITO transparent electrode material, is produced only in some countries such as China, there is a small amount of indium reserves globally, and a large amount of costs are required to produce the indium. In addition, the indium has a high and inconsistent resistance value and thus has a disadvantage in that emitted LED light cannot exhibit desired and constant brightness. For this reason, there is a limitation in that the transparent LED utilizing the ITO cannot be utilized as a high-performance and low-priced transparent electrode material.

[0005] The ITO, in fact, has been used as the transparent electrode material with the largest market share, but due to a limitation in terms of economic feasibility, restrictive performance, and the like, researches and technology development, which utilize new materials, are being consistently conducted. There are metal meshes, nanowires (Ag nanowires), carbon nanotubes (CNTs), conductive polymers, graphene, and the like as transparent electrode materials that attract the attention as next-generation materials. Among the materials, the metal mesh is a new material that occupies 85% of the materials substituted for the ITO, and the metal mesh is low in price and has high conductivity, such that the market related to the metal mesh expands in view of utilization.

[0006] A transparent LED display, which utilizes the metal mesh, has much better conductivity than a transparent display in the related art, makes it easy to perform maintenance, saves resources, greatly reduces environmental pollution, and has economic feasibility resulting from a reduction in manufacturing costs. In addition, the metal mesh may be widely applied for various purposes and may be likely to be applied and utilized as a new transparent electrode material for various products.

[Disclosure]

[Technical Problem]

[0007] The present application has been made an effort to provide a transparent light emitting element display using a metal mesh pattern.

[Technical Solution]

[0008] An exemplary embodiment of the present application provides a transparent light emitting element display comprising: a transparent substrate; at least one light emitting element which is provided on the transparent substrate; and a first common electrode wiring portion, a second common electrode wiring portion, and a signal electrode wiring portion which are provided on the transparent substrate, in which all of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion comprise metal mesh patterns, respectively, each of the metal mesh patterns, which constitute the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, has a standard deviation of a line width which is 20% or less, a standard deviation of a pitch which is 10% or less, and a standard deviation of a line height which is 10% or less, and the metal mesh patterns are provided in a region having an area of 80% or more of an overall area on the transparent substrate.

[Advantageous Effects]

[0009] According to the exemplary embodiment of the present application, the metal mesh patterns, which have the same line width, the same line height, and the same pitch, are applied to the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, and as a result, it is possible to reduce wiring recognition. In addition, since the metal mesh patterns are provided within the entire region of the effective screen portion on the transparent substrate except for the region in which the light emitting element is provided, it is possible to reduce resistance by maximizing the areas of the common electrode wiring portions.

[0010] In addition, according to the exemplary embodiment of the present application, it is possible to reduce wiring recognition by minimizing the widths of the disconnected portions that separate the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion.

[Description of Drawings]

[0011]

FIG. 1 is a view schematically illustrating electrode wiring of a transparent light emitting element display according to an exemplary embodiment of the present application.

FIG. 2 is a view schematically illustrating signal transmission between electrodes and a flow of a power supply in the transparent light emitting element display according to the exemplary embodiment of the present application.

FIGS. 3 and 4 are views each schematically illustrating an electrode pad portion of the transparent light emitting element display according to the exemplary embodiment of the present application.

FIG. 5 is a view schematically illustrating a metal mesh pattern according to the exemplary embodiment of the present application.

FIG. 6 is a view schematically illustrating a metal mesh pattern in the related art.

FIG. 7 is a view schematically illustrating an image operated by the transparent light emitting element display according to the exemplary embodiment of the present application.

FIG. 8 is a view schematically illustrating a line width, a line height, and a pitch of the metal mesh pattern according to the exemplary embodiment of the present application.

<Explanation of Reference Numerals and Symbols>

[0012]

- 10: First common electrode wiring portion
- 20: Second common electrode wiring portion
- 30: Light emitting element
- 40: Power supply unit
- 50: Signal electrode wiring portion
- 60: Disconnected portion
- 70: Metal mesh pattern
- 80: Line width of metal mesh pattern
- 90: Line height of metal mesh pattern
- 100: Pitch of metal mesh pattern
- 110: Transparent substrate

[Best Mode]

[0013] Hereinafter, the present application will be described in detail.

[0014] A transparent LED display provides urban residents with various spectacles by providing information service and creating sceneries, and demands for the transparent LED display are increased in various fields. The ITO, in fact, has been used up to now as the transparent electrode material with the largest market share, but due to a limitation in terms of economic feasibility, restrictive performance, and the like, researches and technology development, which utilize new materials, are being consistently conducted.

[0015] More specifically, transparent electrode wiring was formed by using Ag nanowires or transparent metal oxide (ITO, IZO, etc.) in order to implement a transparent LED display in the related art. However, because the Ag nanowire or the transparent metal oxide (ITO, IZO, etc.) has high resistance, the number of operating LEDs is restricted, and as a result, there is a limitation in increasing an area of the transparent LED display. In addition, in a case in which a

thickness of the Ag nanowire or the transparent metal oxide is increased to reduce the resistance, there occurs a problem that transmittance of the transparent LED display deteriorates.

[0016] Therefore, the present application is characterized by applying a metal mesh pattern to transparent electrode wiring of a transparent light emitting element display in order to provide the transparent light emitting element display having excellent resistance properties and visibility.

[0017] A transparent light emitting element display according to an exemplary embodiment of the present application comprises: a transparent substrate; at least one light emitting element which is provided on the transparent substrate; and a first common electrode wiring portion, a second common electrode wiring portion, and a signal electrode wiring portion which are provided on the transparent substrate, in which all of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion comprise metal mesh patterns, respectively, each of the metal mesh patterns, which constitute the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, has a standard deviation of a line width which is 20% or less, a standard deviation of a pitch which is 10% or less, and a standard deviation of a line height which is 10% or less, and the metal mesh patterns are provided in a region having an area of 80% or more of an overall area on the transparent substrate.

[0018] In the exemplary embodiment of the present application, at least four electrode pad portions, which electrically connect the light emitting element with the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, may be provided between the transparent substrate and the light emitting element. In this case, as illustrated in FIGS. 3 and 4 to be described below, no metal mesh pattern may be provided within at least a part of a region between the at least four electrode pad portions.

[0019] In the exemplary embodiment of the present application, two or more light emitting elements may be provided on the transparent substrate, and the two or more light emitting elements may be connected in series to the signal electrode wiring portion. The number of light emitting elements is not particularly limited and may be appropriately selected by those skilled in the art in consideration of the purpose or the like of the transparent light emitting element display. More specifically, the number of light emitting elements is related to resistance of an electrode, and the number of light emitting elements may be increased if the electrode has sufficiently low resistance and the display has a large area. Resolution is increased if the number of light emitting elements is increased in a state in which the area remains the same, and the area of the display is increased if the number of light emitting elements is increased in a state in which the interval remains the same, such that an electric wire line of an electric power supply unit may be reduced, and as a result, the number of light emitting elements may be appropriately selected by those skilled in the art in consideration of the purpose or the like of the transparent light emitting element display.

[0020] In the exemplary embodiment of the present application, the two or more light emitting elements may be connected in series to the signal electrode wiring portion and connected in series to the first common electrode wiring portion and the second common electrode wiring portion. The first common electrode wiring portion and the second common electrode wiring portion provide the amount of electric current sufficient to operate the light emitting element, and the light emitting element may be connected in series to the signal electrode wiring portion because it is possible to send a signal with only a low electric current when sending a color signal of the light emitting element. If the respective electrodes are connected in parallel to the power supply unit to operate all of the light emitting elements and send a signal unlike the structure in the present application, all of the respective electrode widths need to be different from one another to adjust a resistance value in accordance with an arrangement distance between the light emitting elements (the electrode connected to the farthest light emitting element has the largest width), and it is difficult to implement a low-resistance electrode due to a spatial restriction to an electrode arrangement region because the multiple light emitting elements are provided.

[0021] In the exemplary embodiment of the present application, the signal electrode wiring portion may be provided between the first common electrode wiring portion and the second common electrode wiring portion.

[0022] In the exemplary embodiment of the present application, the first common electrode wiring portion may be a (+) common electrode wiring portion, and the second common electrode wiring portion may be a (-) common electrode wiring portion. In addition, the first common electrode wiring portion may be a (-) common electrode wiring portion, and the second common electrode wiring portion may be a (+) common electrode wiring portion.

[0023] The electrode wiring of the transparent light emitting element display according to the exemplary embodiment of the present application is schematically illustrated in the following FIG. 1.

[0024] According to the exemplary embodiment of the present application, a channel is formed to have a structure in which the signal electrode wiring portion passes between the (+) common electrode wiring portion and the (-) common electrode wiring portion, such that the electrode wiring is not extended for each light emitting element and may be connected, as a common electrode, to the (+) common electrode wiring portion and the (-) common electrode wiring portion. Signal transmission between electrodes and a flow of a power supply in the transparent light emitting element display according to the exemplary embodiment of the present application is schematically illustrated in the following FIG. 2.

[0025] In the exemplary embodiment of the present application, at least four electrode pad portions, which electrically connect the light emitting element with the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, may be provided between the transparent substrate and the light emitting element. According to the exemplary embodiment of the present application, four electrode pad portions, which connect

[0026] In the exemplary embodiment of the present application, the four electrode pad portions may comprise two signal electrode pad portions, one first common electrode pad portion, and one second common electrode pad portion. The two signal electrode pad portions are signal in-out pad portions for a light emitting element and may be provided at ends of the signal electrode wiring portions, respectively, and the first common electrode pad portion and the second common electrode pad portion may be provided at an end of the first common electrode wiring portion and an end of the second common electrode wiring portion, respectively. The ends mean regions in which the light emitting element is provided at an upper side thereof and the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion are electrically connected to the light emitting element.

[0027] In addition, at least one capacitor pad portion may be additionally comprised on the transparent substrate. In the exemplary embodiment of the present application, the number of capacitor pad portions may be two.

[0028] The capacitor pad portion is a pad to which a capacitor is attached, and the capacitor may serve to stabilize an electric current to be supplied to the light emitting element.

[0029] The following FIGS. 3 and 4 are views each schematically illustrating an electrode pad portion of the transparent light emitting element display according to the exemplary embodiment of the present application. FIGS. 3 and 4 are views illustrating a case in which four electrode pad portions and two capacitor pad portions are provided.

[0030] More specifically, in FIGS. 3 and 4, part A illustrates a (+) common electrode wiring portion, part B illustrates a (-) common electrode wiring portion, and part C illustrates a signal electrode wiring portion. In addition, in FIGS. 3 and 4, electrode pad portions 1 and 2 are signal in-out pad portions for a light emitting element, that is, electrode pad portions provided to be connected to ends of the signal electrode wiring portion, an electrode pad portion 3 is a (+) pad portion of the light emitting element, that is, an electrode pad portion provided to be connected to an end of the (+) common electrode wiring portion, and an electrode pad portion 4 is a (-) pad portion of the light emitting element, that is, an electrode pad portion provided to be connected to an end of the (-) common electrode wiring portion. In addition, a capacitor pad portion 5 is a capacitor (+) pad portion, and a capacitor pad portion 6 is a capacitor (-) pad portion.

[0031] Parts A, B, and C comprise metal mesh patterns, and no metal mesh pattern is provided between the electrode pad portions 1 to 4. In addition, the electrode pad portions 1 to 4 and the capacitor pad portions 5 and 6 comprise no metal mesh pattern, and the entire region of each of the pad portions may be made of metal. More specifically, since the electrode pad portions and the capacitor pad portions are portions to be covered by the welded light emitting element, the electrode pad portions and the capacitor pad portions comprise no metal mesh pattern, and the entire region of each of the pad portions may be made of metal.

[0032] Intervals between the electrode pad portions and the capacitor pad portions may be each independently 0.1 mm to 1 mm. With the aforementioned intervals, it is possible to prevent a short-circuit in consideration of a tolerance when performing screen printing with solder paste for forming the light emitting element later.

[0033] The shape of each of the electrode pad portions and the capacitor pad portions is not particularly limited and may be a quadrangular shape. In addition, a size of each of the electrode pad portions and the capacitor pad portions may be, but not limited only to, 0.1 mm² to 1 mm².

[0034] The four electrode pad portions may be joined to one light emitting element. That is, in the exemplary embodiment of the present application, in a case in which multiple light emitting elements are provided on a transparent substrate, the respective light emitting elements may be joined to the four electrode pad portions.

[0035] In the exemplary embodiment of the present application, the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion may comprise metal mesh patterns, respectively, which have the same line width, the same line height, and the same pitch. In the present application, the configuration in which the metal mesh patterns have the same line width means that a standard deviation of the line width is 20% or less, particularly, 10% or less, and more particularly, 5% or less. In addition, in the present application, the configuration in which the metal mesh patterns have the same line height means that a standard deviation of the line height is 10% or less, particularly, 5% or less, and more particularly, 2% or less. In addition, in the present application, the configuration in which the metal mesh patterns have the same pitch means that a standard deviation of the pitch is 10% or less, particularly, 5% or less, and more particularly, 2% or less.

[0036] In the exemplary embodiment of the present application, the metal mesh patterns may be provided within the entire region of an effective screen portion on the transparent substrate except for the region in which the light emitting element is provided. More specifically, the metal mesh patterns may be provided within a region having an area of 80% or more and 99.5% or less of an overall area on the transparent substrate. In addition, based on the overall area on the transparent substrate, the metal mesh patterns may be provided within a region having an area of 80% or more and

99.5% or less of an area of a region except for an FPCB pad portion region and a light emitting element pad portion region provided on the transparent substrate. In the present application, the FPCB pad portion region may comprise an FPCB pad portion for applying external power, and an area of the FPCB pad portion region may be equal to or larger than an overall area of the FPCB pad portion and equal to or smaller than 3 times the overall area of the FPCB pad portion. In addition, in the present application, the light emitting element pad portion region comprises the electrode pad portions, and an area of the light emitting element pad portion region may be equal to or larger than 1.5 times the overall area of the electrode pad portions and equal to or smaller than 3 times the overall area of the electrode pad portions.

[0037] In the exemplary embodiment of the present application, the metal mesh pattern may satisfy the following Expression 1.

[Expression 1]

$$(P - W)^2 / P^2 = 0.8$$

[0038] In Expression 1, P represents the pitch of the metal mesh pattern, and W represents the line width of the metal mesh pattern.

[0039] In the exemplary embodiment of the present application, pattern shapes in the technical field may be used as the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion. More specifically, the metal mesh pattern may comprise a polygonal pattern having one or more shapes of a triangle, a quadrilateral, a pentagon, a hexagon, and an octagon.

[0040] The metal mesh pattern may comprise a straight line, a curve, or a closed curve formed of a straight line or a curve.

[0041] Since the metal mesh patterns may be provided within the entire region of the effective screen portion of the upper surface of the transparent substrate except for the region in which the light emitting element is provided, it is possible to obtain a maximally acceptable wiring region, and thus it is possible to improve resistance properties of the transparent light emitting element display. More specifically, surface resistance of the metal mesh pattern may be 0.1 Ω/sq or less.

[0042] The pitch of the metal mesh pattern may be 100 μm to 1,000 μm , 100 μm to 600 μm , or 100 μm to 300 μm , but the pitch of the metal mesh pattern may be adjusted by those skilled in the art in accordance with desired transmittance and conductivity.

[0043] A material of the metal mesh pattern is not particularly limited, but may comprise one or more types of metal and metal alloys. The metal mesh pattern may comprise, but not limited only to, gold, silver, aluminum, copper, neodymium, molybdenum, nickel, or an alloy thereof.

[0044] The line height of the metal mesh pattern is not particularly limited, but may be 3 μm or more and 20 μm or less or 10 μm or less in terms of conductivity of the metal mesh pattern and economic feasibility of a forming process. More specifically, the line height of the metal mesh pattern may be 3 μm to 20 μm , or 3 μm to 10 μm .

[0045] The line width of the metal mesh pattern may be, but not limited only to, 50 μm or less, 25 μm or less, or 20 μm or less. The smaller line width of the metal mesh pattern may be advantageous in terms of transmittance and wiring recognition but may cause a reduction in resistance, and in this case, the reduction in resistance may be improved by increasing the line height of the metal mesh pattern. The line width of the metal mesh pattern may be 5 μm or more.

[0046] An aperture ratio of the metal mesh pattern, that is, a ratio of an area, which is not covered by the pattern, may be 70% or more, 85% or more, or 95% or more.

[0047] According to the exemplary embodiment of the present application, the metal mesh patterns, which have the same line width, the same line height, and the same pitch, are applied to the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, and as a result, it is possible to reduce wiring recognition. If the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion do not have the same line width, the same pitch, or the same line height, recognition of the wiring portions may be increased, which is not preferable.

[0048] In the exemplary embodiment of the present application, the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion may be separated from one another by disconnected portions where no metal mesh pattern is provided. The disconnected portion means a region in which a part of the metal mesh pattern is disconnected and electrical connection is disconnected. A width of the disconnected portion may mean a distance between nearest ends of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion which are spaced apart from one another. A width of the disconnected portion may be, but not limited only to, 80 μm or less, 60 μm or less, 40 μm or less, or 30 μm or less. The width of the disconnected portion may be 5 μm or more.

[0049] The metal mesh pattern according to the exemplary embodiment of the present application is schematically illustrated in the following FIG. 5, and a metal mesh pattern in the related art is schematically illustrated in the following

FIG. 6.

[0050] In addition, a line width 80, a line height 90, and a pitch 100 of the metal mesh pattern according to the exemplary embodiment of the present application are schematically illustrated in the following FIG. 8. The line width, the line height, and the pitch of the metal mesh pattern may be measured by using a method known in the technical field. For example, a method of observing and measuring an SEM cross section, a measurement method using a non-contact surface shape measurer (optical profiler), a measurement method using a stylus surface profilometer (Alpha-Step or Surfacar Profiler), or the like may be used.

[0051] According to the exemplary embodiment of the present application, it is possible to reduce wiring recognition by minimizing the widths of the disconnected portions that separate the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion.

[0052] In the exemplary embodiment of the present application, the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion may be formed by independent printing processes, respectively, or may be formed simultaneously by one printing process. Therefore, the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion may have the same line width, the same pitch, and the same line height.

[0053] In the exemplary embodiment of the present application, since a printing method is used to form the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, which have thin and precise line widths, may be formed on the transparent substrate. A printing method such as offset printing, screen printing, gravure printing, flexo-printing, inkjet printing, and nano-imprinting may be used as the printing method, but the printing method is not particularly limited, and a combination of the one or more methods may also be used. A roll-to-roll method, a roll-to-plate method, a plate-to-roll method, or a plate-to-plate method may be used as the printing method.

[0054] In the exemplary embodiment of the present application, a reverse offset printing method may be applied to implement a precise metal mesh pattern. To this end, in the present application, a method may be performed in which ink, which may serve as a resist at the time of performing etching, is applied entirely onto the silicone-based rubber called a blanket, unnecessary parts are primarily removed by using an intaglio plate with a carved pattern called a cliché, the printed pattern remaining on the blanket is secondarily transferred onto a substrate such as a film or glass on which metal or the like is deposited, and then the transferred pattern is subjected to a firing process and an etching process to form a desired pattern. In this method, since the substrate on which metal is deposited is used, uniformity of the line height is ensured within the entire region, such that there is an advantage in that resistance in a thickness direction may be uniformly maintained. In addition, in the present application, the printing method may comprise a direct printing method of forming a desired pattern by directly printing and then firing conductive ink by using the aforementioned reverse offset printing method. In this case, the line height of the pattern is flattened by pressing pressure, and conductivity may be imparted by a heat firing process, a microwave firing process, a laser partially firing process, or the like that makes connection made by mutual surface fusion of metal nanoparticles.

[0055] In the exemplary embodiment of the present application, a glass substrate or a plastic substrate, which is known in the technical field, may be used as the transparent substrate, but the transparent substrate is not particularly limited.

[0056] In the exemplary embodiment of the present application, the light emitting element provided on the transparent substrate may be formed by using a material and a method known in the technical field.

[Mode for Invention]

[0057] Hereinafter, the exemplary embodiments described in the present specification will be exemplified through Examples. However, it is not intended that the scopes of the exemplary embodiments are limited by the following Examples.

<Examples>

<Experimental Examples 1 to 4>

[0058] A raw material made by plating a transparent film (Polyester Film V7200 of SKC) with Cu and a dry film resist (DFR, SPG-152 of Asahi Chemical Industry) were laminated. Thereafter, exposure was performed in a state in which a pattern mask was attached thereto, and then development was performed, such that a desired DFR pattern was formed. Thereafter, Cu etching and DFR separation were performed to manufacture a desired Cu wiring pattern (the Cu wiring pattern was provided within a region having an area of 80% or more of the entire area on the transparent film). The Cu wiring pattern was formed to have the structure illustrated in the following FIG. 3, and a line width, a pitch, a line height, a width of a disconnected portion, and the like of the Cu wiring pattern are shown in the following Table 1. A standard

deviation of the line width, the pitch, the line height, the width of the disconnected portion, and the like of the Cu wiring pattern was 2% or less.

[0059] Low-temperature solder paste was printed onto an electrode pad portion by screen printing, and then LEDs were mounted on the solder paste. Thereafter, a solder paste reflow process was performed at about 170°C, such that metal in the solder paste bound and bonded the electrode pad portion and an LED pad portion.

[Table 1]

	Experimental Example 1	Experimental Example 2	Experimental Example 3	Experimental Example 4
Line Width (μm)	20	20	20	30
Pitch (μm)	200	200	200	200
Aperture Ratio (%)	81	81	81	72
Line Height (μm)	5	2	5	5
Width of Disconnected Portion (μm)	30	30	100	30
Resistance (Ω/sq)	0.045	0.110	0.045	0.03
Wiring Recognition	OK	OK	NG	OK
Transmittance (%)	72	72	72	63
LED Lighting	OK	NG	OK	OK

[0060] The wiring recognition was determined based on recognition of disconnection and channel with the naked eye at a spacing distance of 30 cm.

[0061] The LED lighting was determined based on lighting of all of the 484 LEDs in a sheet of 0.5 m $\times$ 0.5 m, the LED lighting was evaluated as OK when all of the 484 LEDs were turned on, and the LED lighting was evaluated as NG when there were the LEDs that were not turned on.

[0062] An image operated by the transparent light emitting element display according to the exemplary embodiment of the present application is schematically illustrated in the following FIG. 7.

[0063] The transmittance was measured by using COH-400 of Nippon Denshoku Industries Co., Ltd.

<Comparative Example 1>

[0064] Comparative Example 1 was manufactured in the same manner as Experimental Example 1 except that electrode wiring was separately formed in the respective LEDs in Experimental Example 1. A line width, a pitch, a line height, a width of a disconnected portion, and the like of the Cu wiring pattern of Comparative Example 1 are shown in the following Table 2.

[Table 2]

	Experimental Example 1	Comparative Example 1
Line Width (μm)	20	20
Pitch (μm)	200	200
Aperture Ratio (%)	81	84
Line Height (μm)	5	5
Width of Disconnected Portion (μm)	30	30
Linear Resistance (Ω)	1	12
Electrode Width (mm)	20	1.74
Electrode Length (mm)	440	460
LED Lighting	OK	NG

[0065] The linear resistance was measured based on electrode wiring resistance to the last LED in a column in a power supply unit.

[0066] The electrode width (interval between LEDs) of 20 mm is maintained to the last LED in Experimental Example 1, but in a case in which electrode wiring is formed in the respective LEDs in Comparative Example 1, the wiring width of the last LED in the column is reduced to 1.74 mm because the electrode width is divided and distributed to equalize resistance to the respective LEDs.

[0067] The electrode length to the last LED is 440 mm in Experimental Example 1 because the 22 LEDs are disposed at an interval of 20 mm in the single column, while the electrode length is 460 mm in Comparative Example 1 because the interval of 20 mm between the LEDs is added to 440 mm.

[0068] As seen in the results, according to the exemplary embodiment of the present application, since the metal mesh patterns, which have the same line width, the same line height, and the same pitch, are applied to the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, it is possible to reduce wiring recognition. In addition, since the metal mesh patterns are provided within the entire region of the effective screen portion on the upper surface of the transparent substrate except for the region in which the light emitting element is provided, it is possible to reduce resistance by maximizing the areas of the common electrode wiring portions.

[0069] In addition, according to the exemplary embodiment of the present application, it is possible to reduce wiring recognition by minimizing the widths of the disconnected portions that separate the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion.

Claims

1. A transparent light emitting element display comprising:

a transparent substrate;
at least one light emitting element which is provided on the transparent substrate; and
a first common electrode wiring portion, a second common electrode wiring portion, and a signal electrode wiring portion which are provided on the transparent substrate,
wherein all of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion comprise metal mesh patterns, respectively,
each of the metal mesh patterns, which constitute the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, has a standard deviation of a line width which is 20% or less, a standard deviation of a pitch which is 10% or less, and a standard deviation of a line height which is 10% or less, and
the metal mesh patterns are provided in a region having an area of 80% or more of an overall area on the transparent substrate.

2. The transparent light emitting element display of claim 1, wherein at least four electrode pad portions, which electrically connect the light emitting element with the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion, are provided between the transparent substrate and the light emitting element.

3. The transparent light emitting element display of claim 2, wherein the at least four electrode pad portions comprise two signal electrode pad portions, one first common electrode pad portion, and one second common electrode pad portion.

4. The transparent light emitting element display of claim 1, wherein the two or more light emitting elements are provided, and the two or more light emitting elements are connected in series to the signal electrode wiring portion.

5. The transparent light emitting element display of claim 1, wherein the signal electrode wiring portion is provided between the first common electrode wiring portion and the second common electrode wiring portion.

6. The transparent light emitting element display of claim 1, wherein the metal mesh pattern satisfies the following Expression 1,

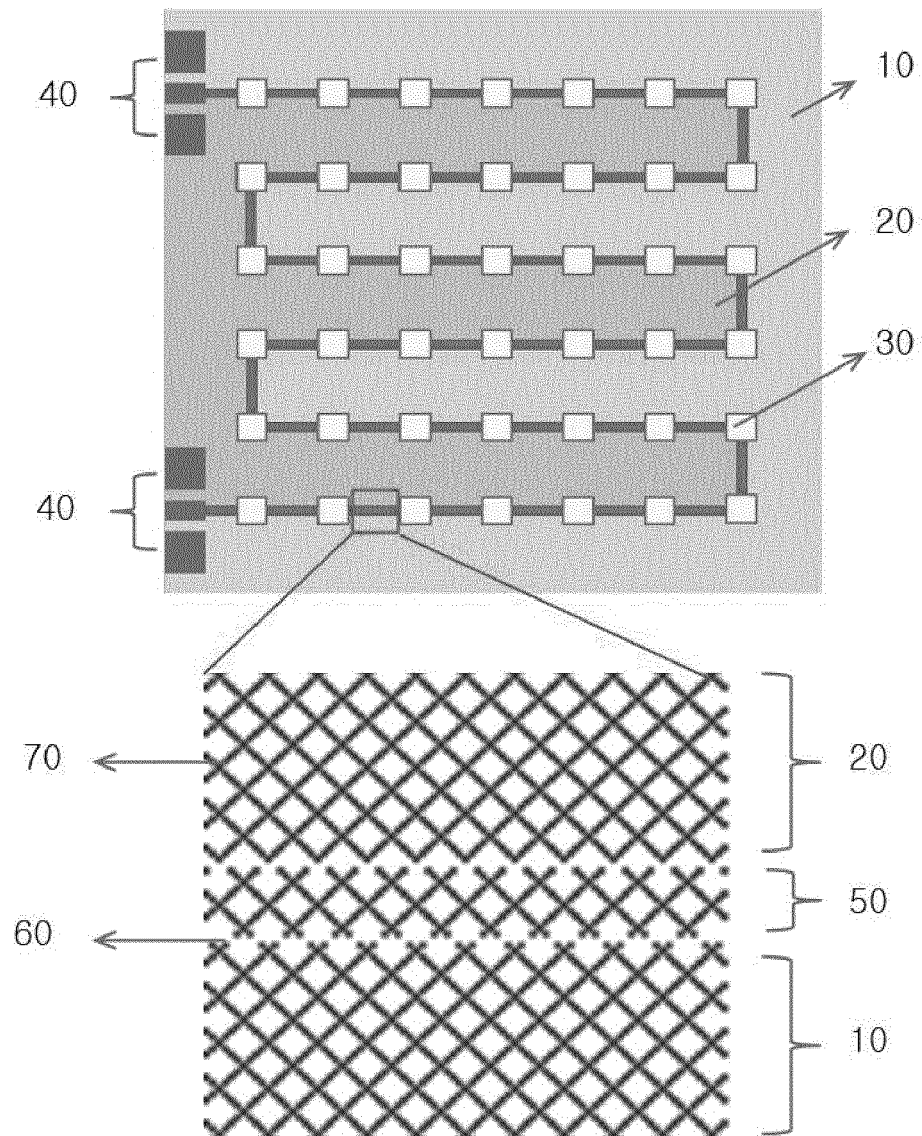
[Expression 1]

$$(P - W)^2 / P^2 = 0.8$$

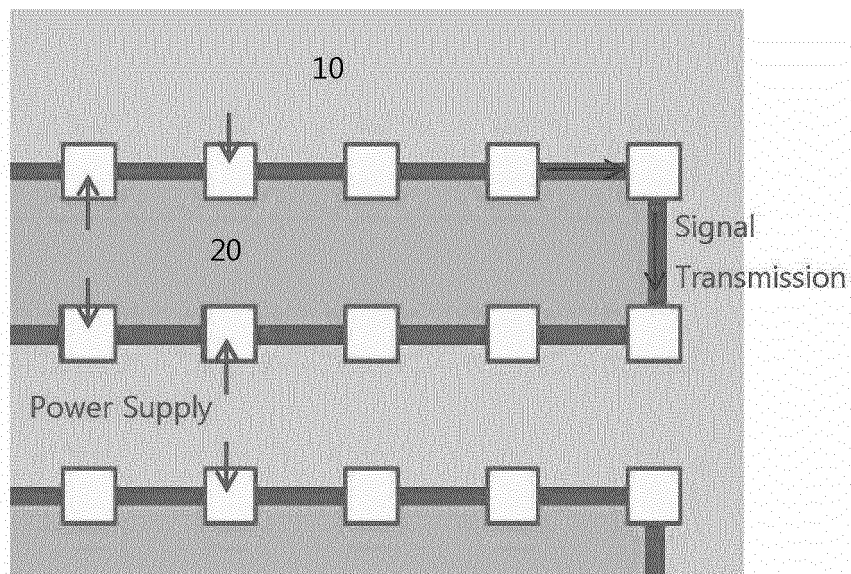
wherein P represents the pitch of the metal mesh pattern, and W represents the line width of the metal mesh pattern.

7. The transparent light emitting element display of claim 1, wherein surface resistance of the metal mesh pattern is 0.1 Ω /sq or less.
8. The transparent light emitting element display of claim 1, wherein the line width of the metal mesh pattern is 50 μ m or less, the pitch of the metal mesh pattern is 100 μ m to 1,000 μ m, and the line height of the metal mesh pattern is 3 μ m or more.
9. The transparent light emitting element display of claim 1, wherein the metal mesh patterns of the first common electrode wiring portion, the second common electrode wiring portion, and the signal electrode wiring portion are separated from one another by disconnected portions, respectively, where no metal mesh pattern is provided, and a width of the disconnected portion is 80 μ m or less.
10. The transparent light emitting element display of claim 2, wherein sizes of the electrode pad portions are each independently 0.1 mm² to 1 mm².
11. The transparent light emitting element display of claim 2, wherein intervals between the at least four electrode pad portions are each independently 0.1 mm to 1 mm.
12. The transparent light emitting element display of claim 1, wherein the metal mesh pattern comprises gold, silver, aluminum, copper, neodymium, molybdenum, nickel, or an alloy thereof.
13. The transparent light emitting element display of claim 1, further comprising:
at least one capacitor pad portion on the transparent substrate.

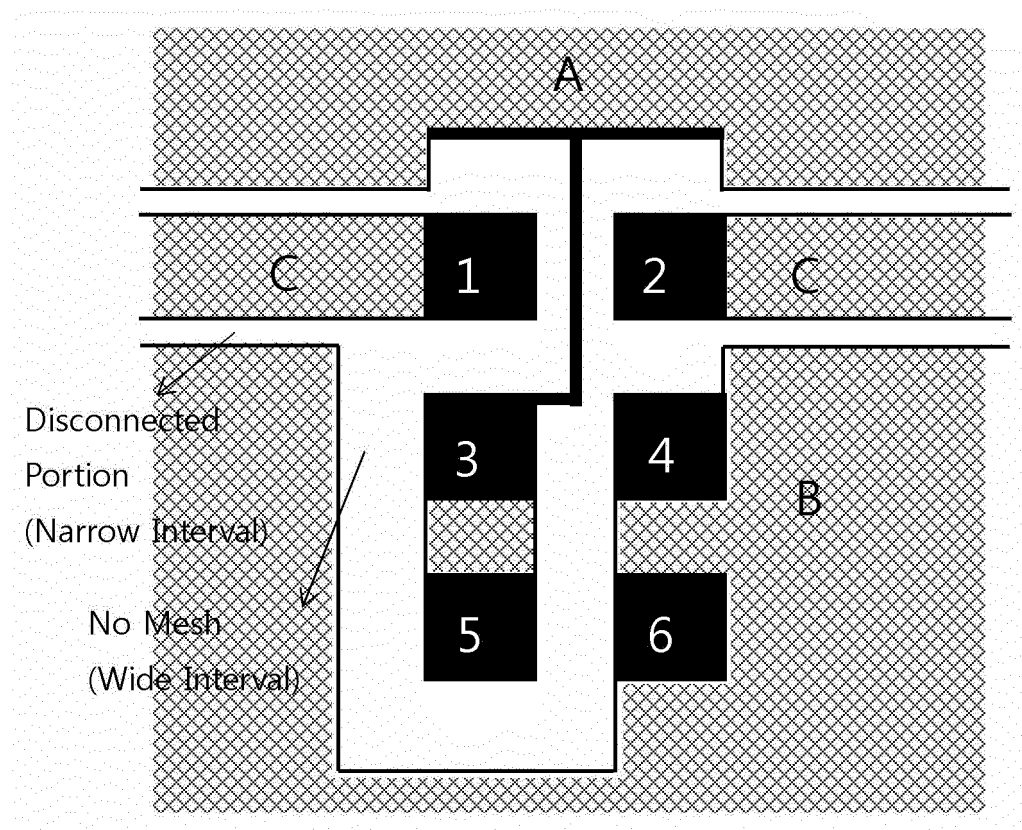
[Figure 1]



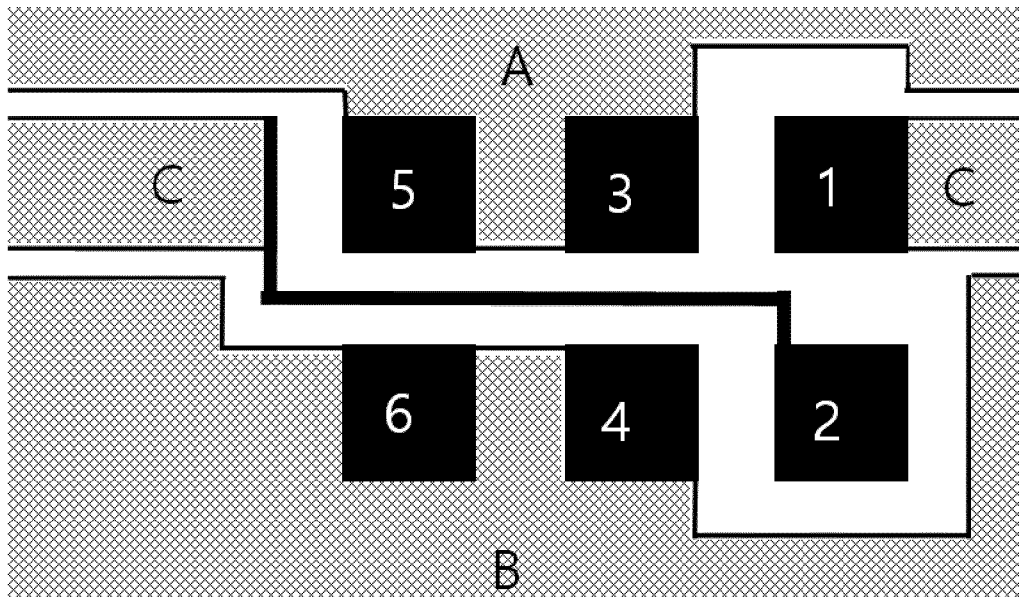
[Figure 2]



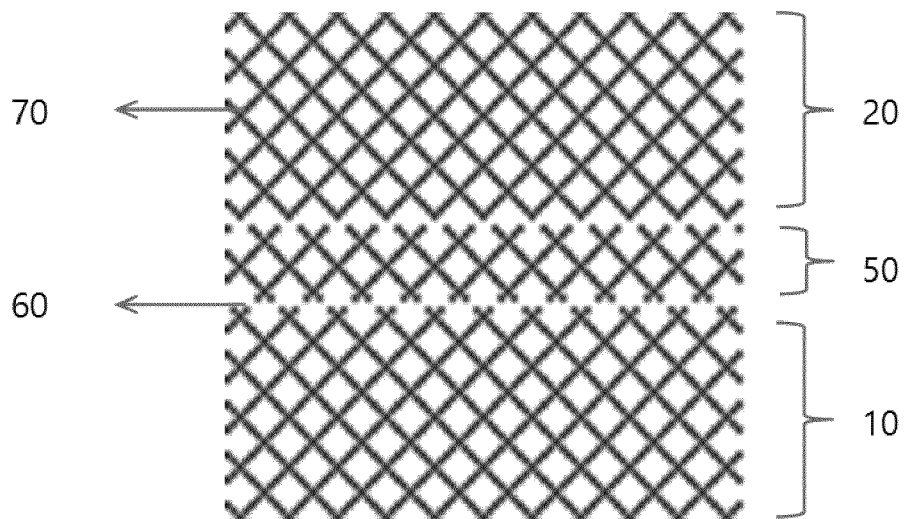
[Figure 3]



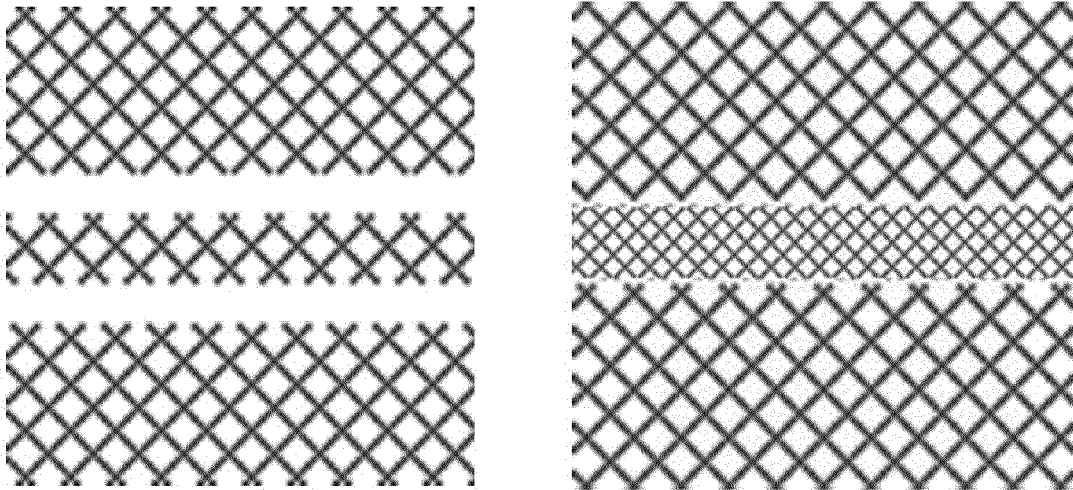
[Figure 4]



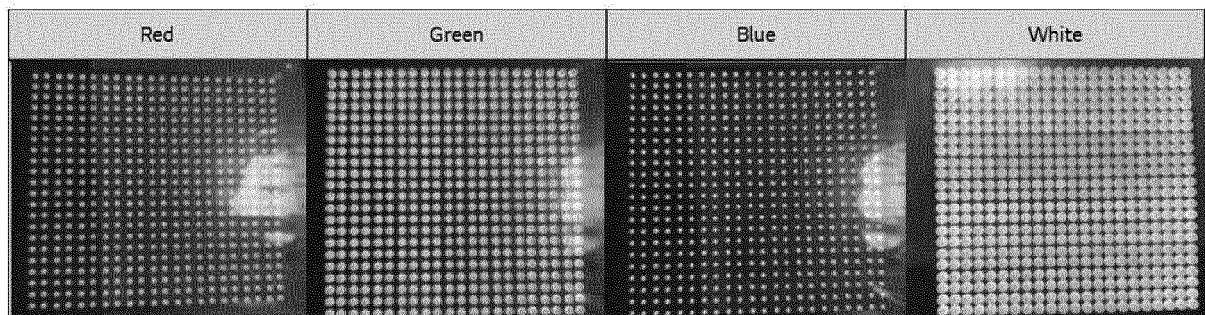
[Figure 5]



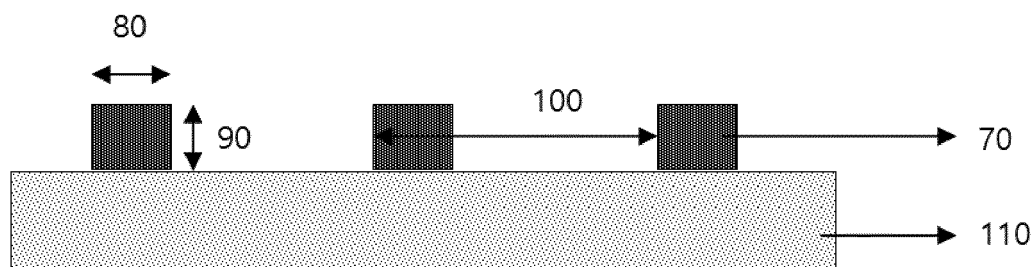
[Figure 6]



[Figure 7]



[Figure 8]



INTERNATIONAL SEARCH REPORT

International application No.

PCT/KR2018/008407

A. CLASSIFICATION OF SUBJECT MATTER

H01L 27/15(2006.01)i, H01L 33/36(2010.01)i, H01L 33/62(2010.01)i

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

H01L 27/15; F21V 19/00; G09F 9/30; G09F 9/33; G09G 3/20; H01L 21/77; H01L 27/32; H01L 33/00; H05K 1/02; H01L 33/36; H01L 33/62

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Korean Utility models and applications for Utility models: IPC as above

Japanese Utility models and applications for Utility models: IPC as above

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

eKOMPASS (KIPO internal) & Keywords: transparency, light-emitting element, common electrode, signal electrode, metal mesh

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
Y	US 6097351 A (NISHIDA, Shinsuke) 01 August 2000 See column 6, lines 17-65, column 13, lines 46-65 and figures 2-3, 14.	1-13
Y	WO 2016-178322 A1 (TOSHIBA HOKUTO ELECTRONICS CORPORATION) 10 November 2016 See paragraphs [0011]-[0082] and figures 1-20.	1-13
Y	WO 2016-019699 A1 (SHI, Yijian) 11 February 2016 See claim 1 and figures 3A-3B.	13
A	KR 10-2016-0103818 A (KUMHO ELECTRIC INC.) 02 September 2016 See paragraphs [0039]-[0052] and figures 3-4.	1-13
A	KR 10-1105887 B1 (PT&K CO., LTD. et al.) 16 January 2012 See paragraphs [0018]-[0026] and figures 2a-2b.	1-13

☐ Further documents are listed in the continuation of Box C.☒ See patent family annex.

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"O" document referring to an oral disclosure, use, exhibition or other means

"P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

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"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&" document member of the same patent family

Date of the actual completion of the international search

31 OCTOBER 2018 (31.10.2018)

Date of mailing of the international search report

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Telephone No.

Form PCT/ISA/210 (second sheet) (January 2015)

INTERNATIONAL SEARCH REPORT
Information on patent family members

International application No.

PCT/KR2018/008407

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KR 10-2016-0103818 A	02/09/2016	US 2016-0245491 A1 WO 2016-137056 A1	25/08/2016 01/09/2016
KR 10-1105887 B1	16/01/2012	KR 10-2011-0119155 A	02/11/2011

REFERENCES CITED IN THE DESCRIPTION

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Patent documents cited in the description

- KR 1020170096101 [0001]

专利名称(译)	具有透明发光元件的显示装置		
公开(公告)号	EP3660903A1	公开(公告)日	2020-06-03
申请号	EP2018837540	申请日	2018-07-25
[标]申请(专利权)人(译)	乐金化学股份有限公司		
申请(专利权)人(译)	LG化学有限公司.		
当前申请(专利权)人(译)	LG化学有限公司.		
[标]发明人	LEE KUN SEOK SON YONG GOO LEE SEUNG HEON		
发明人	LEE, KUN SEOK SON, YONG GOO LEE, SEUNG HEON		
IPC分类号	H01L27/15 H01L33/36 H01L33/62		
CPC分类号	H01L25/0753 H01L33/62		
优先权	1020170096101 2017-07-28 KR		
外部链接	Espacenet		

摘要(译)

根据本申请的示例性实施方式的透明发光元件显示器包括：透明基板；以及透明基板。至少一个发光元件设置在透明基板上；以及设置在透明基板上的第一公共电极配线部，第二公共电极配线部和信号电极配线部，其中，第一公共电极配线部，第二公共电极配线部以及信号全部电极布线部分分别包括金属网格图案，构成第一公共电极布线部分，第二公共电极布线部分和信号电极布线部分的每个金属网格图案的线宽的标准偏差为：在面积为80%或以下的区域中提供20%以下，间距的标准偏差为10%以下，线高的标准偏差为10%以下，并且将金属网状图案设置为透明基板上的更多面积。

[Figure 1]

